

### ScotCHEM Workshop

#### **Recent Appointees in the Chemical Sciences**

# Be part of Scotland's next generation in innovation.

#### Monday 17th June

Juniper Auditorium V&A Dundee, Riverside Esplanade, Dundee, DD1 4EZ

10.00 - 19.00

Venue information: <a href="https://bit.ly/2TS4vwl">https://bit.ly/2TS4vwl</a>
Register here: <a href="https://bit.ly/2HQqnad">https://bit.ly/2HQqnad</a>

A workshop bringing together industrialists, artists and ScotCHEM's new research leaders.

#### An excellent opportunity to:

- Meet Scotland's next generation chemical science leaders.
- Catalyse creativity by joining our 'Big Ideas' and 'Art meets Science' break-out sessions.
- Two £1k art meets chemistry commissions
- Meet industry scientists
- Meet business people and entrepreneurs.
- Learn about upcoming funding opportunities.
- Discuss collaboration and innovation.

Print Date 21.05.2019 V5.2



## **Provisional Program**

09.30 - 10.00	Coffee and Registration
10.00 - 10.10	Welcome and Introductions
	Dr Bill MacDonald, CEO, ScotCHEM
10.10 - 10.30	Jon Helliwell, Director, CPI
	The Centre for the Process Innovation and the UK's Catapult Centres.
10.30 - 10.50	Dr Matthew Reeves, Materials Chemistry, KTN
	TBC
10.50 - 11.10	Dr Heather Anderson, Assistant Director of Major Projects,
	The University of Strathclyde
	TBC
11.10-11.30	Dr Deborah Carr, DASA.
	The UK's defence research funder.
11.30 - 12.30	Early Career Researcher Pitches*
	Our new PI's have 2 minutes to pitch their research.
	Artists and designers welcome to join.
13.00 - 14.00	Lunch*
14.00 - 14.20	Dr Mike McPherson, Patent Attorney, Creation IP
	What you need to know about Intellectual Property.
14.20 - 14.30	Andrew Bissell, CEO, Sunamp
	Commercially driven innovation.
14.30 - 14.40	Dr Jeremy Shears, Chief Scientist Biosciences, Shell Research Ltd
	TBC
15.00 - 14.40	Workshop*
	<u>EPSRC Big Ideas</u> session – big research problems need big ideas.
15.40 - 16.40	Workshop **
	Art meets science with ASCUS.
16.40 -16.50	Closing remarks*
17.00	Dinner and Drinks at the V&A*

Artists and designers are welcome to attend the whole day, however \* indicates a recommended session, and \*\* indicates an essential session. The V&A collection is on hand to enjoy if you wish to drop in and out.

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